Tool ID: 614 Tool Location: 121

## **Equipment Information Sheet**

# **Rudolph FTM**

Manager: Michael Skvarla 607-254-4674 Calls to staff phones will be automatically forwarded to Backup: Alan R. Bleier 607-254-4931

their cell phones during accessible hours. At other times leave a message or send them an email.

#### **SAFETY**

• No unusual hazards during normal operation

### **USAGE RESTRICTIONS SCHEDULING/SIGN-UP RESTRICTIONS** MATERIALS COMPATIBILITY CATEGORY

Minimum Tool Time: 0 minutes

Tool Category 5: Class A and B Metals and Compounds	
Allowed	Not Allowed
Tool category 1/1E, 2, 3, and 4 materials	
Silicon Based Substrates and Films	
III/V compound Semiconductors	
Glass Substrates	
PECVD and ALD Films	
Cured organics and baked Photoresist	
CNF Class A, B, and Refractory metals	
Exposed Gold, Silver, Copper	
Alkali and Alkaline Compounds	
Organic/Biology Molecules prepared- w/salt buffers	
High Vapor Pressure Materials (Mg, Ca, Zn)*	* Some tool restrictions on high vapor pressure materials may apply
Soft organic materials	

High Vapor Pressure Metals and Compounds are materials that have a vapor pressure above 1e-6 Torr at 400 C.

## **Additional Material Restrictions and Exceptions**

- You need to know the index of refraction of the film being measured
- Measurement area is 2 X 6 mm
- Film optical thickness must be between 300 and 5,000 nm

Last Updated: 08/05/2024